

Application No.: 10/519,339  
Filing Date: August 15th, 2005

### AMENDMENTS TO THE SPECIFICATION

Please amend paragraph in page 14 line 14 as follows to correct a clerical errors.  
Insertions are shown underlined while deletions are ~~struck through~~.

A thickness of the substrate layer may be appropriately selected depending on an application. Generally, a thickness of the conductive resin film with substrate layer and the low resistance layer combined is 5  $\mu\text{m}$  to 0.5 mm, preferably 10  $\mu\text{m}$  to 200 $\mu\text{m}$ . A volume resistance of the conductive resin film as a whole in the thickness direction is 0.01 to 5  $\Omega\text{cm}$ , preferably 3  $\Omega\text{cm}$  or less.

Please amend Table 3 in page 28 as follows to correct a clerical errors. Insertions are shown underlined while deletions are ~~struck through~~.

Table 3

Volume rate of a resin	Volume rate of a fine carbon fiber	Volume resistance of a conductive film	
		Example	Referential Example
50%	50%	0.02 $\Omega\text{cm}$	A film could not be formed.
60%	40%	0.05 $\Omega\text{cm}$	A film could not be formed.
70%	30%	0.08 $\Omega\text{cm}$	0.24 $\Omega\text{cm}$
80%	20%	0.11 $\Omega\text{cm}$	1.20 $\Omega\text{cm}$
90%	10%	0.27 $\Omega\text{cm}$	50 $\Omega\text{cm}$